## IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Hiroki SATO

Conf. 6778

Application No. 10/588,187

Group 1762

Filed August 2, 2006

ALKOXIDE COMPOUND, MATERIAL FOR THIN FILM FORMATION, AND PROCESS FOR THIN FILM FORMATION

## INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In compliance with Rules 1.97 and 1.98, and in ful-fillment of the duty of disclosure under Rule 1.56, the cited documents are made of record on the enclosed PTO Form-1449.

As the USPTO has waived the requirement under 37 CFR 1.98(a)(2)(i) for submitting a copy of each cited U.S. patent and patent publication for applications filed after June 30, 2003, copies of the cited U.S. references are <u>not</u> enclosed, as the present application is filed after June 30, 2003. Copies of the cited foreign patent documents and/or non-patent literature are enclosed.

A concise explanation of the relevance of these items is that these references were cited by the Chinese Patent Office in an Official Action. A copy of the Chinese Official Action in which they were cited is attached hereto, with an English translation.

Docket No. 8007-1114 Appln. No. 10/588,187

Respectfully submitted,

YOUNG & THOMPSON

Robert J. Patch, Reg. No. 17,355

209 Madison Street, Suite 500

Alexandria, VA 22314

Telephone (703) 521-2297

Telefax (703) 685-0573

(703) 979-4709

RJP/dmw

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